

DE LA RECHERCHE À L'INDUSTRIE



SCREEN PRINTING IN SACLAY

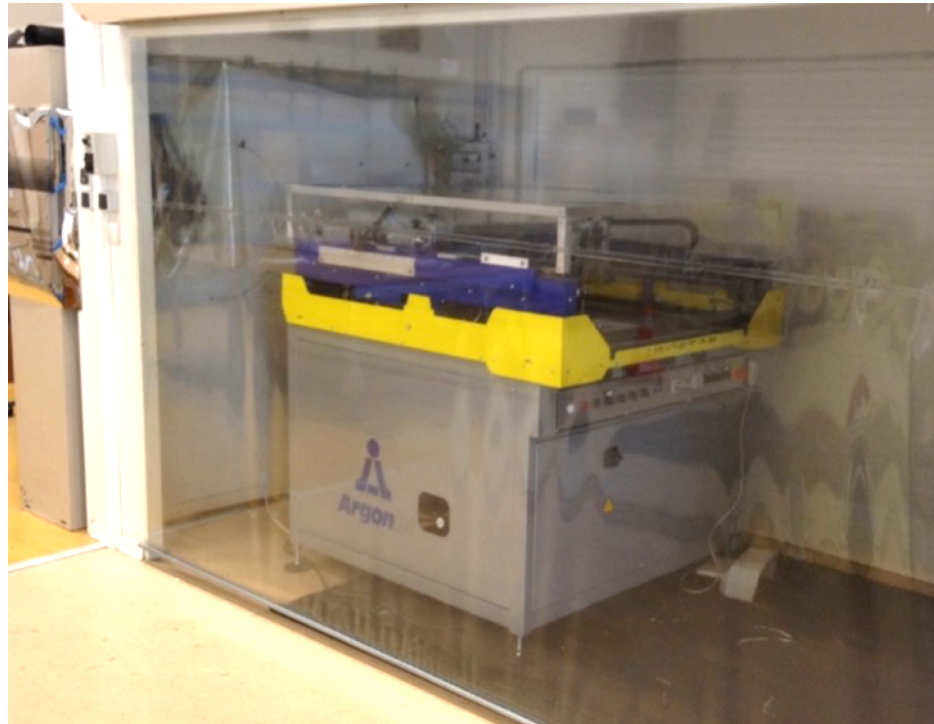
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- Bulk Micromegas detectors are manufactured in Saclay MPGD workshop since 3 years (~ 150 units).
- In 2014 the workshop was upgraded with a serigraphy machine in order to print resistive pattern on top of readout PCB before bulk processing.
- Goal of the serigraphy @ Saclay:
 - thin strips and/or thin inter strips ($< 100 \mu\text{m}$) on large surface (600 mm x 600 mm)
 - Gain experience with resistive strips
 - R&D program:
 - different patterns of resistive coating (strips, plain layer, pad,...)
 - different resistive paste (dilution or carbon adding)
 - use of insulating paste and/or silver conductive paste
- This new machine is part of a “fab-lab” together with the bulk workshop and several test benches in the same geographic area that will allow us to built and test prototypes.

- The Argon Unostar E serigraphy machine is a professional tool well suited for the type of resistive polymer to be used. Investment is ~ 30 k€ (ANR Splam)
- Maximum surface is 700 mm * 700 mm
- End 2014 a first test was done using a demonstration screen with several patterns to train IRFU technicians on this machine



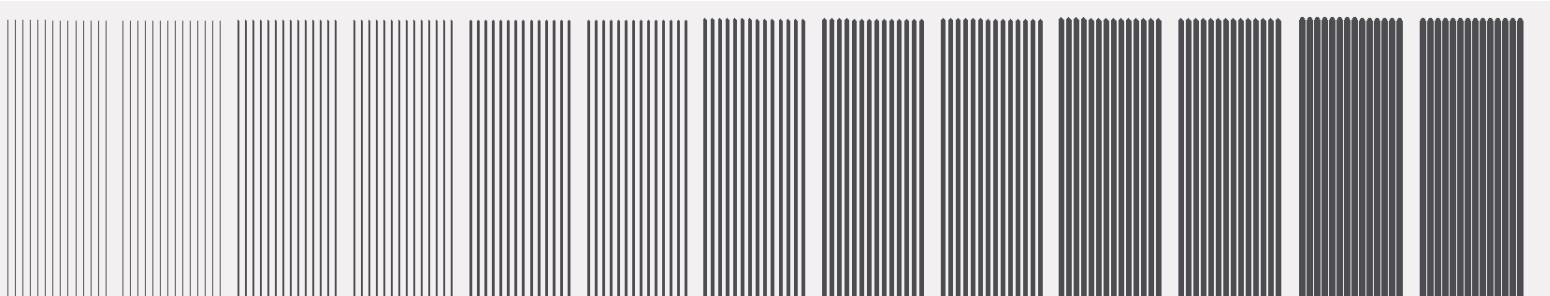
- Screen:
 - Stainless-steel mesh M325, SD90/40 at 15°
 - ENDUCTION on screen of 6-8 μ (measure = 8 μ m)
 - Theoretical thickness of paste deposition ~ 48 μ m
 - tension of the screen mesh = 28 N/cm in both direction
- Resistive polymers :ESL RS 12115
- Use without addition of solvent
- Substrat for deposition: Kapton of 50 μ m and mylar of 60 μ m
- Parameters of machine Argon Unostar E (average speed and pressure)

- The test screen had several types of strips with a pitch of 700 μm , from very thin strip to very thin inter-strip. The strip length was 500 mm.
- Various other patterns (square, circle, connector, ...) of various size where also on the same screen

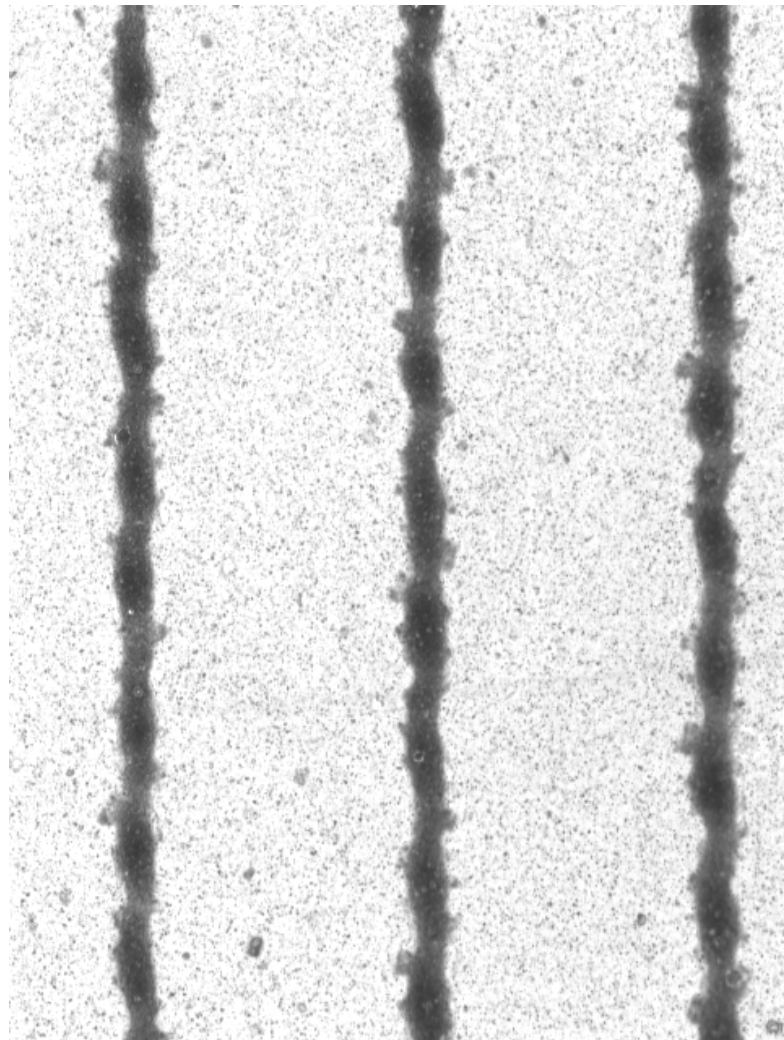
	Strip (μm)	Inter (μm)
Zone 1	50	650
Zone 2	100	600
Zone 3	150	550
Zone 4	200	500
Zone 5	250	450
Zone 6	300	400
Zone 7	350	350
Zone 8	400	300
Zone 9	450	250
Zone 10	500	200
Zone 11	550	150
Zone 12	600	100
Zone 13	650	50

Zone 1

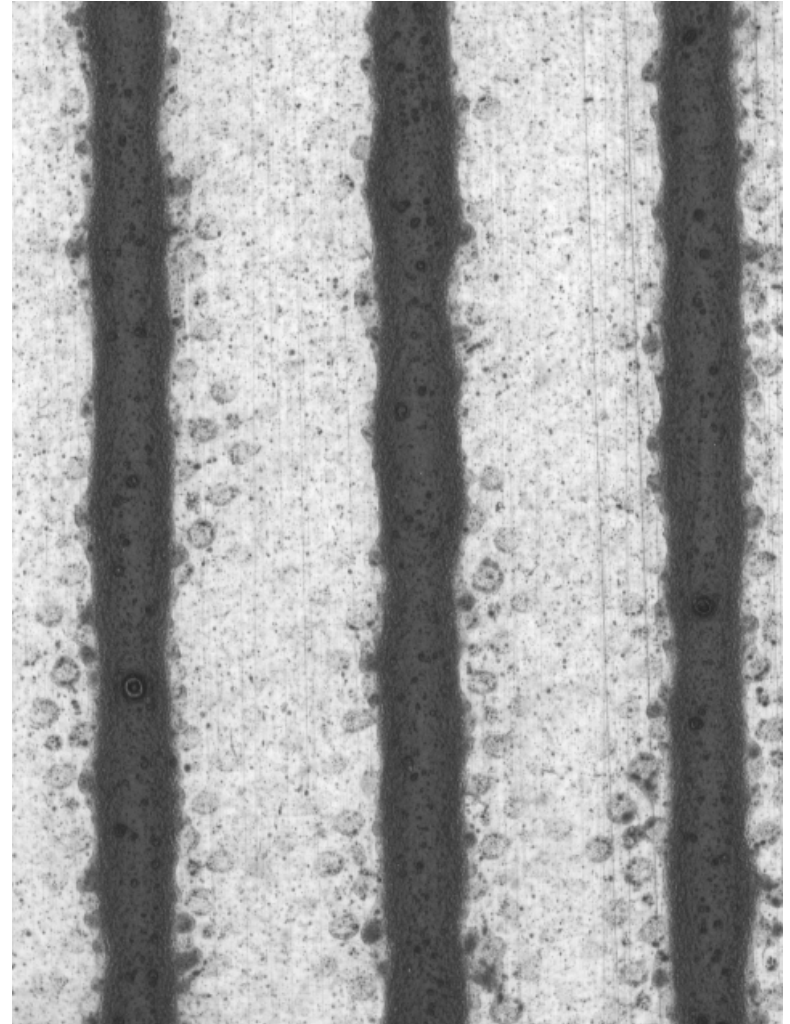
Zone 13



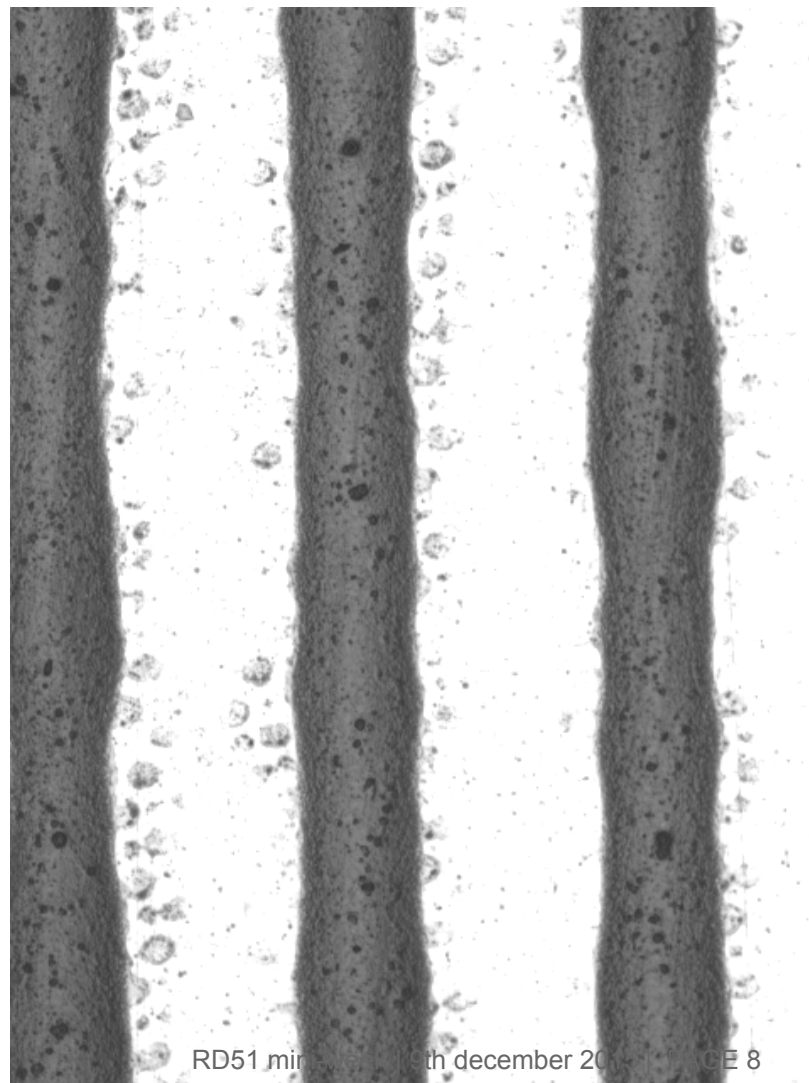
- Strip of 50 μm on screen
- Result \rightarrow strips of $\sim 100 \mu\text{m}$



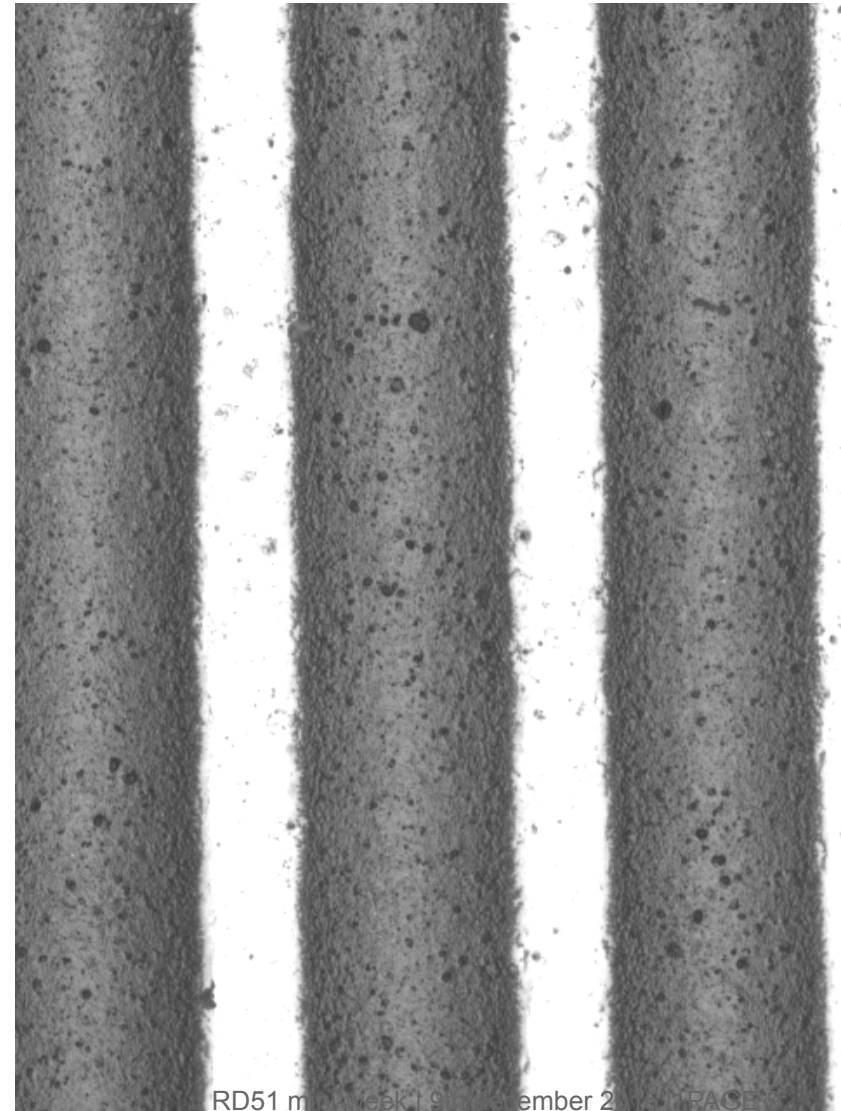
- Strip of 100 μm on screen
- Result \rightarrow strips of $\sim 153 \mu\text{m}$



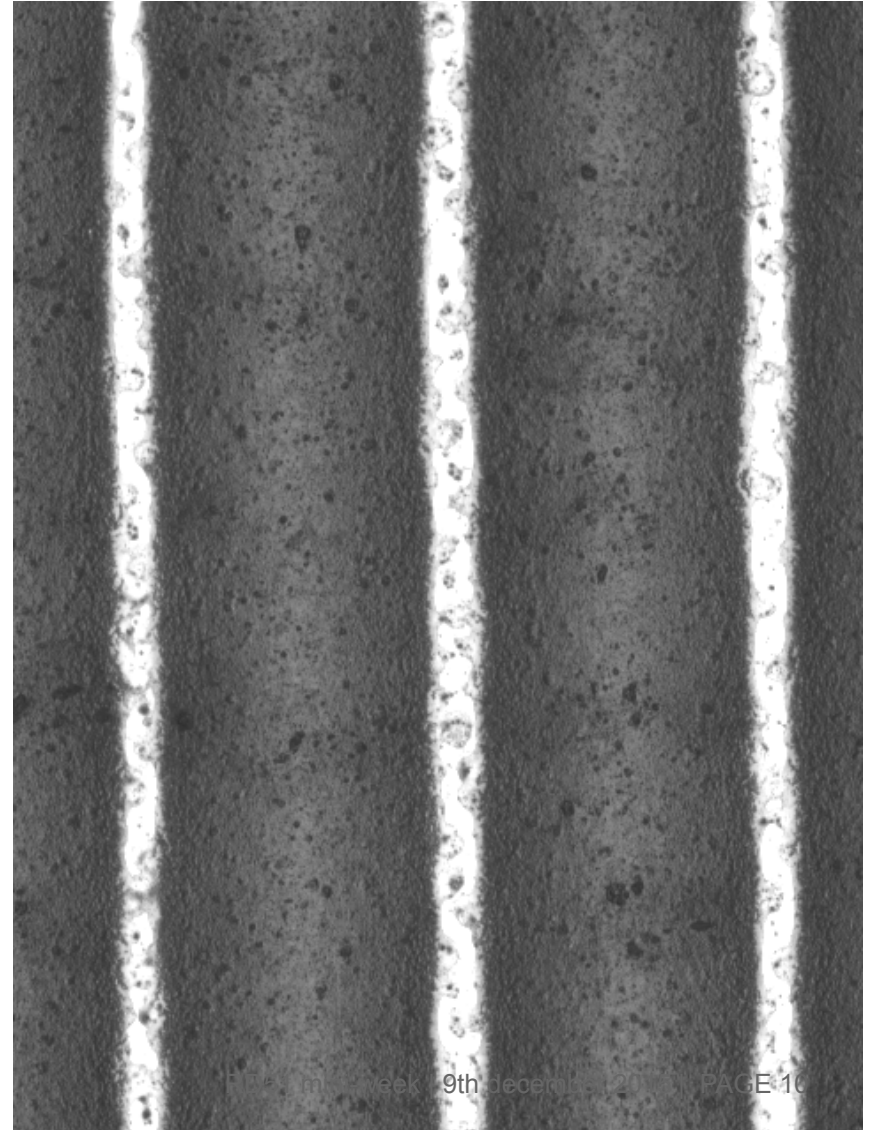
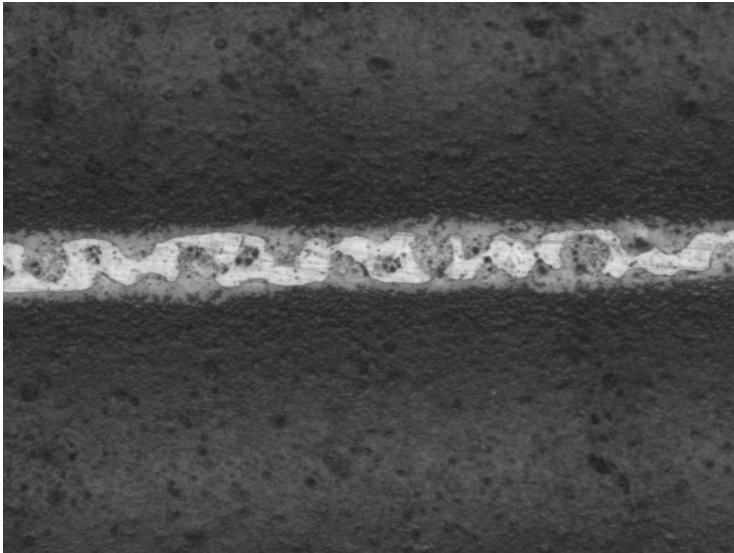
- Strip of 150 μm on screen
- Result \rightarrow strips of $\sim 275 \mu\text{m}$
- Thickness: 22 μm



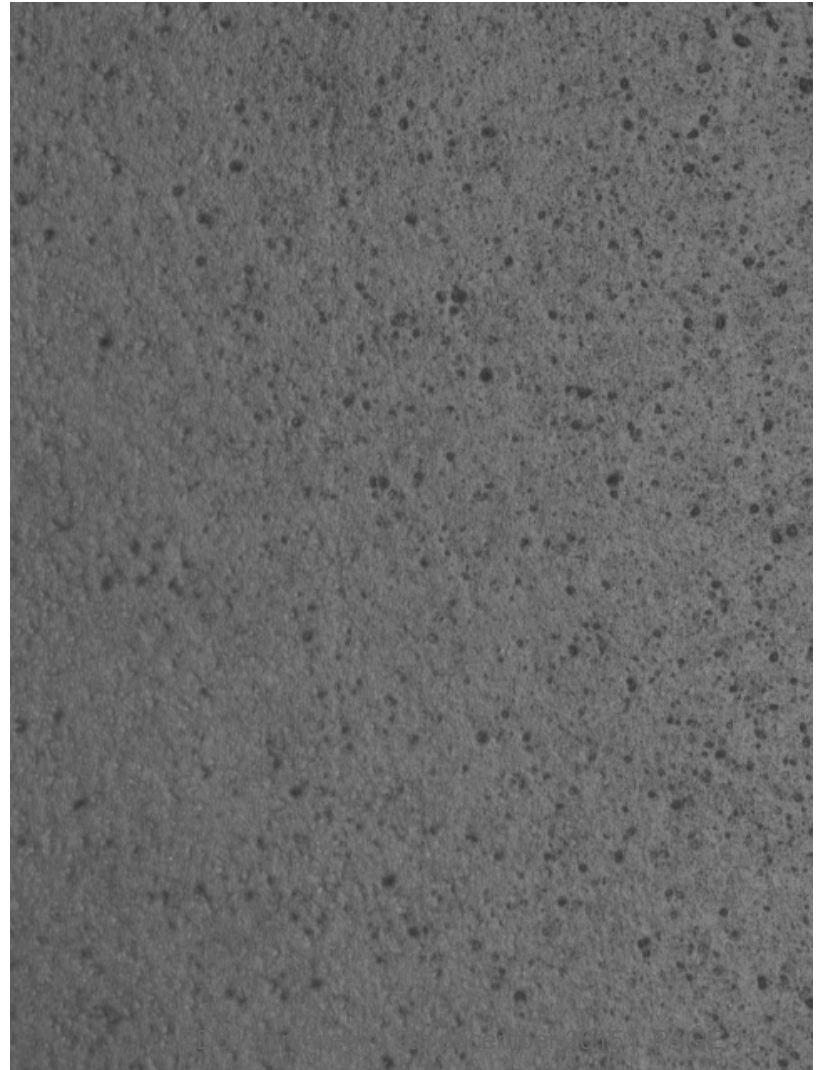
- Strip of 300 μm on screen
- Result \rightarrow strips of $\sim 482 \mu\text{m}$
- Thickness: 36 μm

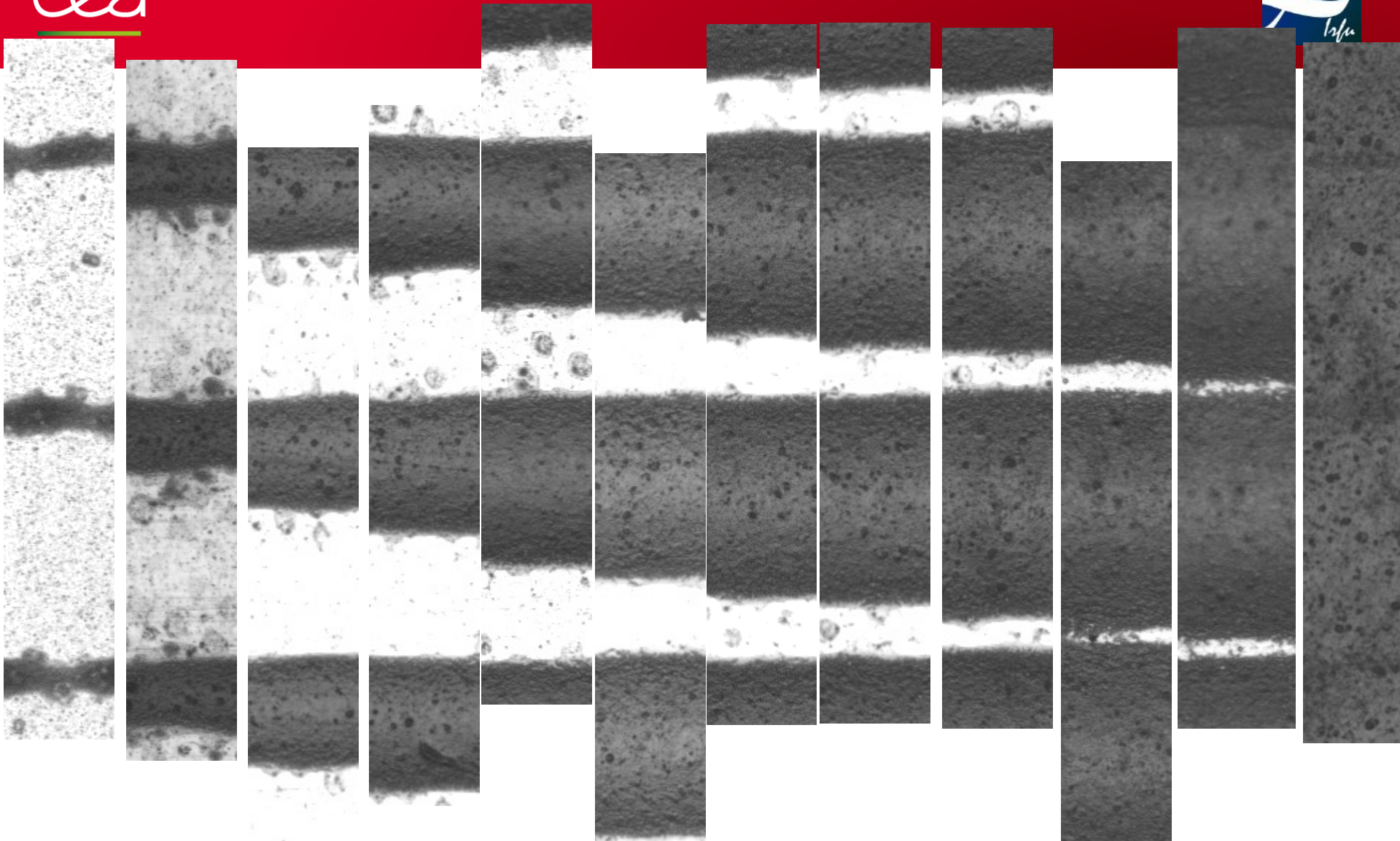


- Strip of 450 μm on screen
- Result \rightarrow strips of $\sim 630 \mu\text{m}$



- Strip of 650 μm on screen (inter = 50 μm)
- Result \rightarrow plain resistive layer
- Thickness: \sim 51 μm





Z1

Z2

Z3

Z4

Z5

Z6

Z7

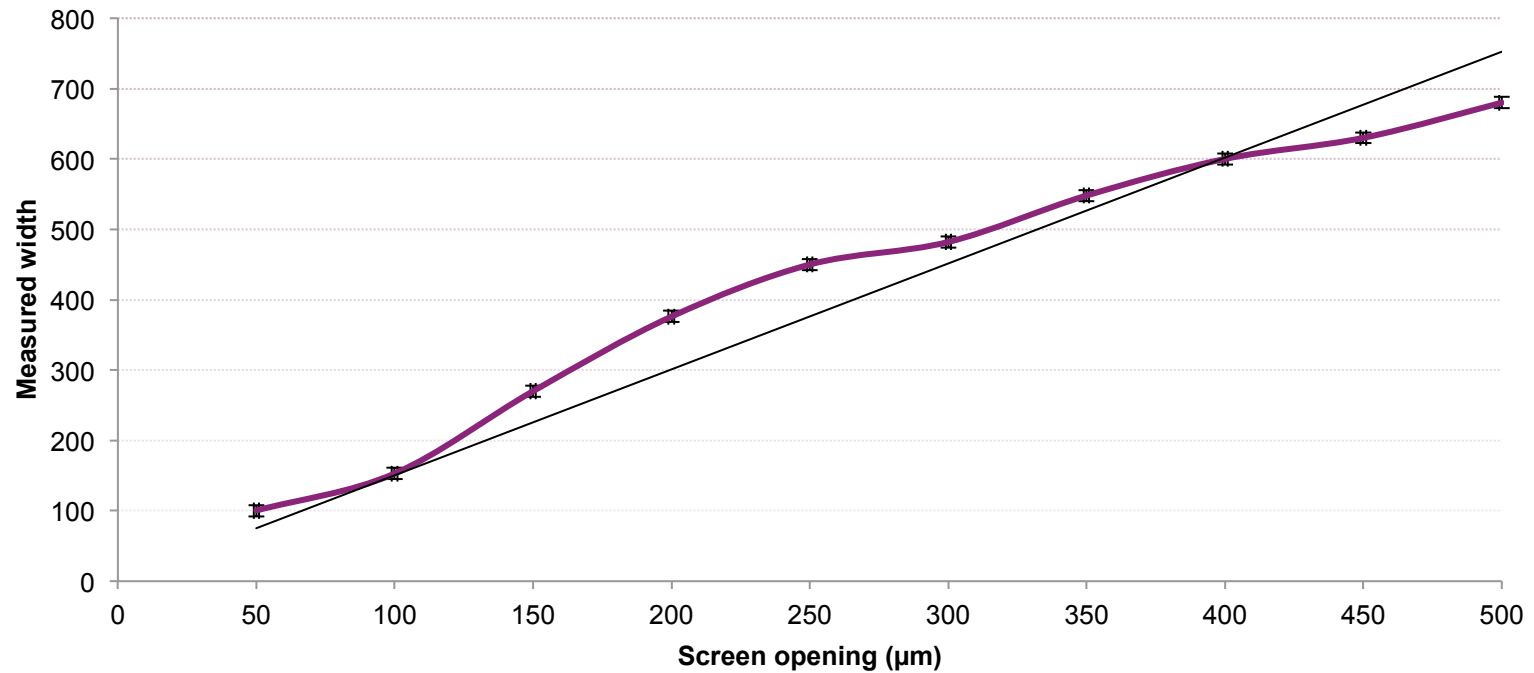
Z8

Z9

Z10

Z11

Z12



- With this very first test we were able to print strips of 500 mm length very uniform.
- The ratio of measured strip-size over screen opening is $\sim 1,5$

- ❑ Serigraphy + resistivity measurements
 - Two dedicated screens (different mesh down to SCS 45/18) with long strips + pads for resistivity measurement
 - Resistivity versus temperature

- ❑ TF1O- R prototype (Active area 12x12 cm, 128 channels)
 - Several resistive coating (strip, plain, mesh, pixel) will be tested:
 - Serigraphy
 - Metrology
 - resistivity measurement
 - Bulk
 - test with Fe55 and cosmic bench

- ❑ Large 2D prototype (500 mm * 500 mm) with different deposition pattern.